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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/816,170	04/02/2004	Heine Melle Mulder	081468-0309024	7878	
909	7590 08/28/2006		EXAMINER GUTIERREZ, KEVIN C		
	Y WINTHROP SHAW	V PITTMAN, LLP			
P.O. BOX 10 MCLEAN, 1			ART UNIT	PAPER NUMBER	
,			2851		
			DATE MAILED: 08/28/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

			2
	Application No.	Applicant(s)	
Office Action Summer	10/816,170	MULDER ET AL.	
Office Action Summary	Examiner	Art Unit	
	Kevin Gutierrez	2851	_
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period variety reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin vill apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 08 At	<u>ugust 2006</u> .		
2a) ☐ This action is FINAL. 2b) ☒ This	action is non-final.		
3) Since this application is in condition for allowar	nce except for formal matters, pro	secution as to the merits is	
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.	
Disposition of Claims			
4) Claim(s) <u>1-13 and 16-20</u> is/are pending in the a	application.		
4a) Of the above claim(s) is/are withdraw	vn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-13 and 16-20</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/o	r election requirement.		
Application Papers			
9) The specification is objected to by the Examine	r.		
10)⊠ The drawing(s) filed on 21 February 2006 is/are	e: a)⊠ accepted or b)⊡ objecte	d to by the Examiner.	
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the correct	* * * * * * * * * * * * * * * * * * * *	• •	
11) ☐ The oath or declaration is objected to by the Ex	caminer. Note the attached Office	Action or form PTO-152.	
Priority under 35 U.S.C. § 119			
12) ☐ Acknowledgment is made of a claim for foreign a) ☐ All b) ☐ Some * c) ☐ None of:	priority under 35 U.S.C. § 119(a))-(d) or (f).	
1. ☐ Certified copies of the priority documents	s have been received.		
2. Certified copies of the priority documents		on No	
3. Copies of the certified copies of the prior	rity documents have been receive	ed in this National Stage	
application from the International Bureau	ı (PCT Rule 17.2(a)).		
* See the attached detailed Office action for a list	of the certified copies not receive	ed.	
Attachment(s)	_		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) 🔲 Interview Summary Paper No(s)/Mail D		
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date		Patent Application (PTO-152)	

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DETAILED ACTION

Response to Arguments

1. Applicant's arguments, see Remarks (pages 6-11), filed August 8, 2006, with respect to the claims have been fully considered and are persuasive. The rejection of the claims has been withdrawn.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1, 4, 13 and 16 are rejected under 35 U.S.C. 102(b) as being anticipated by Nishi et al. (5,991,009).

Regarding claims 1 and 13, Nishi et al. disclose "a reflective integrator (fig. 1, ref. 7; fly-eye-lens) disposed along an optical axis (AX) of the lithographic apparatus,

the reflective integrator (7) having a rectangular cross-section perpendicular to said optical axis (AX), the cross-section having sides parallel to mutually perpendicular X and Y axes (col. 8, lines 3-4); and

an optical element (8; aperture stop), constructed and arranged to redistribute an intensity distribution exiting the reflective integrator (7) such that the intensity distribution is asymmetric with respect to at least one of the X and Y axes (col. 8, lines 16-17; col. 10, lines 9-14)."

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Regarding claim 4, Nishi et al. disclose "wherein said optical element (8) is disposed downstream of said reflective integrator (7) in a pupil plane of said illumination system (col. 8, lines 12-14)."

Regarding claim 16, Nishi et al. disclose the limitations set forth in claim 1 and further disclose

"an illumination system (1-12) for providing a projection beam of radiation (IL1-2);

a support structure (19; reticle stage) for supporting a patterning device (13; reticle), the patterning device serving to impart the projection beam with a pattern of its cross-section (col. 2, lines 1-4);

a substrate table (17; wafter stage) for holding a substrate (16; wafer);

a projection system (15) for projecting the patterned beam onto a target portion of the substrate (16);

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 1-3 and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Mori (6,337,734). In view of Bowron et al. (6,205,271).

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Regarding claims 1 and 13, Mori discloses a reflective integrator (fig. 1, ref. 4; fly-eye lens) disposed along an optical axis (see fig. 1, where center horizontal middle line of light rays depict is the optical axis) of the lithographic apparatus,

"an optical element (see fig. 1, where the optical element (denoted by a diagonal solid line) located after optical element 7 in the direction away from fly eye lens 4), constructed and arranged to redistribute an intensity distribution exiting the reflective integrator (4) such that the intensity distribution is asymmetric with respect to at least one of the X and Y axes (the beams reflected are set in a change of direction (thus, as well as redistributing intensity) towards a mask 8 and at least 2 sets the of the 3 bundles of light rays are asymmetric to the X or Y axes)."

Mori disclose an optical integrator (4) with its cross-section having sides parallel to mutually perpendicular X and Y axes (col. 1, lines 35-40), but does not disclose "a reflective integrator having a rectangular cross-section."

However, having "a reflective integrator having a rectangular cross-section" is known to the art as it is evident by the teaching of Bowron et al. (see fig. 1A and 1B). Thus, it would have been obvious to one ordinary skilled in the art at the time the invention was made to modify the optical integrator of Mori by having a rectangular cross-section for at least the purpose of reducing the amount of reflections.

Regarding claims 2-3, Mori discloses wherein said optical element is constructed and arranged to rotate an intensity distribution of a beam of radiation around said optical axis over an angle between 5 and 85 degrees" and "wherein said

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angle is 90/n degrees where n is an integer number in a range from 2 to 18 (see fig. 1, where beam the reflected off of the said mirror has changed in direction)."

6. Claims 2-3, 5-12 and 17-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishi et al. in view of Wynne Willson et al. (6,102,554).

Regarding claim 5, Nishi et al. disclose all of the claimed limitations except for "wherein said optical element includes at least one pair of reflective surfaces, said pair of reflective surfaces constructed and arranged to reallocate part of the intensity distribution of said beam."

However, "wherein said optical element includes at least one pair of reflective surfaces, said pair of reflective surfaces constructed and arranged to reallocate part of the intensity distribution of said beam" is known to the art as it is evident by the teaching of Wynne Willson et al. (col. 4, lines 21-23; where at least a pair of blades can be made by various reflective materials and is capable of reallocating part of an intensity distribution of a beam). Thus, it would have been obvious to one ordinary skilled in the art at the time the invention was made to modify the optical element of Nishi et al. by having blades of reflective surfaces for at least the purpose of detecting the illuminance of the beam.

Regarding claim 6, Nishi et al. further disclose "wherein a distance (see fig. 1) between the optical axis (AX) and said part of the intensity distribution upstream of said optical element (8) is equal to said distance downstream of said optical element (see fig. 1, where light rays upstream and downstream from 8 are equal)."

Regarding claim 7, Wynne Willson et al. further disclose "wherein said reflective surfaces include coated mirrors (col. 4, line 22, where the blade material can be made of dichroic glass."

Regarding claim 8, Wyne Willson et al. further disclose "wherein said at least one pair of reflective surfaces are planar and parallel to each other (see fig. 1A, col. 4, lines 41-43, where the blades 10 are parallel and planar) so that a direction of a ray of said beam of radiation upstream of aid optical element equals a direction of said ray downstream of said optical upstream of said optical element (col. 2, lines 46-51)."

Regarding claims 9 and 19, Wyne Willson et al. further disclose "wherein the optical element includes two pairs of reflective surfaces (col. 3, lines 8-10), each pair of reflective surfaces constructed and arranged to reallocate one of two respective poles of said intensity distribution (col. 4, lines 45-47)."

Regarding claims 10 and 20, Wyne Willson et al. further disclose "wherein said optical element includes a plurality of pairs of reflective surfaces constructed and arranged to rotate substantially a whole intensity distribution of said beam of radiation (col. 4, line 22; col. 5, lines 49-52, where the reflective surfaces can reflect substantially a whole intensity distribution with closed blades)."

Regarding claim 11, Wyne Willson et al. further disclose "wherein said plurality of pairs of reflective surfaces (col. 4, line 22) includes radially extending (see fig. 1A, where the blades 10 extend in the radial direction) and tilted mirror blades (col. 5,

lines 47-51, where light is reflected at an angle), the minor blades including a reflective coating at both sides (col. 4, line 22)."

Regarding claim 12, Wyne Willson et al. further disclose "wherein a thickness of said mirror blades varies as a function of distance from the optical axis and as a function of angle around the optical axis (col. 6, lines 24-26)."

Regarding claim 18, Nishi et al. in view of Wyne Willson et al. further disclose the limitations set forth in claims 4-5.

Conclusion

- 7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The following disclose an apparatus that utilizes an optical element and an integrator to rotate a beam intensity: Mulder et al. (US 2005/0134820) and Nishinaga (US 2003/0025890).
- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kevin Gutierrez whose telephone number is (571)-272-5922. The examiner can normally be reached on Monday-Friday: 8:00 a.m. 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Diane Lee can be reached on (571)-272-2399. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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USPTO Customer Service Representative or access to the automated information

system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Kevin Gutierrez Examiner Art Unit 2851

August 17, 2006

Rodney Fuller Primary Examiner

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